## IN THE CLAIMS:

The text of all pending claims, (including withdrawn claims) is set forth below. Cancelled and not entered claims are indicated with claim number and status only. The claims as listed below show added text with <u>underlining</u> and deleted text with <u>strikethrough</u>. The status of each claim is indicated with one of (original), (currently amended), (cancelled), (withdrawn), (new), (previously presented), or (not entered).

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Please AMEND claims 3 and 4 in accordance with the following:

- 1. (ORIGINAL) A mold releasing film for printed circuit board production, which comprises a resin layer (P) containing (A) a polyphenylene ether-based resin in an amount of 50 wt% or more.
- 2. (ORIGINAL) The mold releasing film for printed circuit board production according to claim 1, wherein the resin layer (P) further contains (B) a liquid crystalline polyester in an amount of 0.5 to 50 parts by weight per 100 parts by weight of the total weight of components (A) and (B).
- 3. (CURRENTLY AMENDED) The mold releasing film for printed circuit board production according to claim 2, wherein the resin layer (P) further contains (C) a compound containing <u>a</u> monovalent, divalent, trivalent or tetravalent metal-element, in an amount of 0.1 to 10 parts by weight per 100 parts by weight of the total weight of components (A) and (B).
- 4. (CURRENTLY AMENDED) The mold releasing film for printed circuit board production according to claim 3, wherein the monovalent, divalent, trivalent or tetravalent metal element-comprises at least one of a-divalent Zn element-and a-divalent Mg element.
- 5. (ORIGINAL) The mold releasing film for printed circuit board production according to claim 2, wherein the resin layer (P) further contains (D) a silane compound in an amount of 0.1 to 5 parts by weight per 100 parts by weight of the total weight of components (A) and (B).
- 6. (ORIGINAL) The mold releasing film for printed circuit board production according to claim 5, wherein the silane compound (D) has an amino group.
- 7. (ORIGINAL) The mold releasing film for printed circuit board production according to claim 6, wherein the resin layer (P) further contains (E) a hydrocarbon-based wax in

an amount of 0.1 to 4 parts by weight per 100 parts by weight of the total weight of components (A) and (B).

8. (ORIGINAL) The mold releasing film for printed circuit board production according to claim 1, which has a monolayer structure consisting essentially of the resin layer (P).

## 9. (CANCELED)

- 10. (ORIGINAL) The mold releasing film for printed circuit board production according to claim 9, wherein the elastomer (F) is (G) a partially hydrogenated polymer of a block copolymer of an aromatic vinyl compound and a conjugated diene compound.
- 11. (ORIGINAL) The mold releasing film for printed circuit board production according to claim 10, wherein the content of a bonded aromatic vinyl compound in component(G) is from 5 wt% to 65 wt%.
- 12. (ORIGINAL) The mold releasing film for printed circuit board production according to claim 9, wherein the elastomer (F) is (H) a copolymer of ethylene and a vinyl ester compound.
- 13. (PREVIOUSLY PRESENTED) The mold releasing film for printed circuit board production according to claim 1, obtained by molding through an extrusion tubular method.
- 14. (PREVIOUSLY PRESENTED) The mold releasing film for printed circuit board production according to claim 1, obtained by molding through a T-die extrusion method.
- 15. (PREVIOUSLY PRESENTED) The mold releasing film for printed circuit board production according to claim 1, having a contact angle between the film surface of its outermost surface layer and a water drop of 80° or more.
- 16. (PREVIOUSLY PRESENTED) The mold releasing film for printed circuit board production according to claim 1, wherein the printed circuit board is a flexible printed circuit board.